



**EXPEDITED PROCEDURE – EXAMINING GROUP 2818**

**S/09/471,460**

**PATENT**

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicant:	Thomas A. Figura et al.	Examiner:	Calvin Lee
Serial No.:	09/471,460	Group Art Unit:	2818
Filed:	December 22, 1999	Docket No.:	303.932US4
Title:	USE OF A PLASMA SOURCE TO FORM A LAYER DURING THE FORMATION OF A SEMICONDUCTOR DEVICE		

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**AMENDMENT & RESPONSE UNDER 37 C.F.R. 1.116**

Mail Stop RCE  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

In response to the Final Office Action mailed August 22, 2005, please amend the application as follows:

This response is accompanied by a Petition, as well as the appropriate fee, to obtain a one-month extension of the period for responding to the Office action, thereby moving the deadline for response from November 22, 2005 to December 22, 2005.